



## CATIAV5R21 Chinese version from entry to the master (with CD-ROM) (CAX Engineering Applications Series)(Chinese Edition)

---

By DING YUAN . LIU QING WEI BIAN ZHU

paperback. Book Condition: New. Ship out in 2 business day, And Fast shipping, Free Tracking number will be provided after the shipment. Paperback. Pub Date :2012-12-01 Pages: 509 Publisher: Tsinghua University Press. basic information about the title: CATIA V5 R21 Chinese version from entry to the master (with CD-ROM) (CAX Engineering Applications Series) List Price: 69.00 yuan: D source. Liu Qingwei ed Publisher: Tsinghua University Press Publication Date :2012-12-1 ISBN: 9787302302230 Words: 845.000 yards: 509 Edition: 1 Binding: Paperback: 16 Weight: Editor's Choice Features: start from scratch to learn covers parts design. sheet metal did not count. assembly design. mold design and preparation of numerical control machining program content. The goal: learning through the book. so that readers with independent conventional product design and development. mold design and manufacturing as well as CNC programming capabilities. The executive summary catia v5 r21 Chinese version from entry to the proficient. covers catia v5r21 software configuration. contents of the solid model to create three-dimensional surface design. assembly model design. sheet metal design. mold design and NC machining program design. Book content the Deep and contextual teaching principles arrangements so that the readers can be faster and more in-depth understanding of catia software abstraction. complex commands...

### Reviews

*A top quality publication along with the font used was intriguing to read. I really could comprehend everything using this written e ebook. Its been designed in an remarkably straightforward way and it is only after i finished reading through this publication by which basically altered me, modify the way i believe.*

-- **Cathrine Larkin Sr.**

*Very useful to all of group of people. I actually have read through and so i am certain that i will planning to study yet again once again down the road. I am just very easily can get a satisfaction of looking at a created book.*

-- **Mark Bernier**